

1

Q2 Forum

3 Laser synthesis and
4 processing of atomically
5 thin 2D materialsQ5 Q4 Q3 Kai Xiao ^{1,*} and
David B. Geohegan^{1,*}

7

8 Recent advances in laser synthe-
9 sis and processing of 2D materi-
10 als are described that address
11 key issues of scalable synthesis,
12 precise heterogeneity control, and
13 transformative manufacturing. Laser
14 spectroscopy is used to remotely
15 characterize and optimize the
16 structure and functionality of 2D
17 materials, enabling their *in-situ*
18 diagnostic-based synthesis and
Q6 19 processing.20 Addressing key synthesis
21 challenges of 2D materials by
22 laser-based approaches23 Realizing novel electronic and quantum
24 properties in atomically thin 2D materials
25 requires control over their structural and
26 chemical heterogeneities within individual
27 layers, including defects, dopants, edges,
28 layer stacking, and localized strain [1].
29 However, due to their atomically thin thick-
30 ness and vulnerable structure, many con-
31 ventional synthesis and processing tools
32 developed to process bulk materials, such
33 as ion implantation for chemical doping of
34 semiconductors, are no longer applicable.
35 Tailoring such synthesis and processing
36 techniques for atomically thin 2D materials
37 is essential. In this forum article, we present
38 trending laser-based synthesis and pro-
39 cessing approaches for the growth, doping,
40 thinning, conversion, direct writing, and
41 phase modification of atomically thin 2D
42 materials [2]. Because laser energy can
43 be discretely pulsed and wavelength-
44 tuned, electronic transitions and vibronic
45 modes of 2D crystals can be excitedand spectroscopically probed to enable
the creation of point defects, enable
phase transitions by conversion to heat,
and at higher intensities, achieve atomic
layer-by-layer exfoliation for thinning.
Conversely, laser ablation plasmas can
be intentionally created to supply novel
species and conditions for synthesis, for
example, **hyperthermal kinetic energy
(KE) clusters** (see [Glossary](#)) for low-
energy implantation [3] or amorphous
ultrasmall nanoparticles as precursors
for **laser crystallization** and assembly
of 2D crystals with different phases [4].
In combination, the strong light-matter
interactions in 2D materials enable lasers
to serve not only as synthesis and pro-
cessing tools but as remote optical spec-
troscopic diagnostics to directly measure
and monitor the structural quality, grain
orientation, strain, and defect evolution
in situ by Raman scattering, photolumines-
cence (PL), second harmonic generation,
and ultrafast pump-probe techniques.Precisely managing the layer
number and phase of 2D materials
by laser processingDue to the significant light absorption of
2D materials, **laser thinning** is being devel-
oped as an effective post-growth method to
precisely control layer thickness, which is
crucial for the physical properties of layered
2D materials, such as optical, electronic,
vibrational, and magnetic properties. Both
continuous-wave (CW) and pulsed lasers
offer a variety of photochemical and thermal
options to directly and cleanly remove layers
of **van der Waals (vdW) crystals** on sub-
strates by controllably heating or inducing
photochemical etching reactions in oxi-
dative, wet, or chemical environments
[2,5]. Due to the strong thermal coupling
of the bottom-most layer to the sub-
strate, atomic layer-by-layer thinning can
be reliably accomplished in transition
metal dichalcogenide (TMD) materials,
such as MoS₂, by heating with CW lasers
[6]. In addition, because the band gap
and vibrational modes of TMD flakes

Glossary

Domain rotation: a crystalline grain rotates on
another crystalline grain or substrate.**Hyperthermal kinetic energy (KE) clusters:**
clusters of atoms with translational kinetic energies
well in excess of $k_B T$ (e.g., 1–100 eV/atom in PLD
plasmas).**Laser crystallization:** laser heating or photolysis to
crystallize an amorphous precursor into a crystalline
state.**Laser-induced structural phase transitions:** a
structural change of a material from one phase to
another by laser irradiation.**Laser thinning:** exfoliation of layered materials using
laser heating, ablation, or etching.**Van der Waals (vdW) crystals:** strongly bonded 2D
layers that are bound in the third dimension by weaker
vdW forces between the layers.depend strongly on thickness, Raman 46
and PL spectral peak positions can 47
monitor *in situ* the optical fingerprints 48
of different layer numbers, promising 49
on-demand fabrication of monolayer/ 50
multilayer 2D materials with any desired 51
patterns for device applications. 52Laser crystallization of predeposited amor- 53
phous precursors is another pathway to 54
form 2D crystals. Liu and colleagues re- 55
vealed within the **transmission electron** 56
microscope (TEM) how ultrathin amor- 57
phous WSe_x precursors on suspended 58
graphene and MoSe₂ substrates stepwise 59
laser-crystallize into aligned vdW epitaxial 60
heterostructures [7]. The *in situ* TEM studies 61
revealed a surprising variety of nonclassical 62
crystallization pathways by which nanoscale 63
domains of the crystals assemble into 64
large 2D WSe₂ flakes driven by interac- 65
tions with the monolayer substrates, includ- 66
ing directed diffusion, **domain rotation**, 67
and grain boundary migration. These re- 68
sults are promising for laser direct writing/ 69
crystallization as a transformative approach 70
for the rapid synthesis and processing of 71
2D materials. 72**Laser-induced structural phase tran-** 73
sitions and metastable phases in 2D 74
materials can be triggered by the highly 75
nonequilibrium conditions of laser irradia- 76
tion. Controlling how 2D layers stack with 77

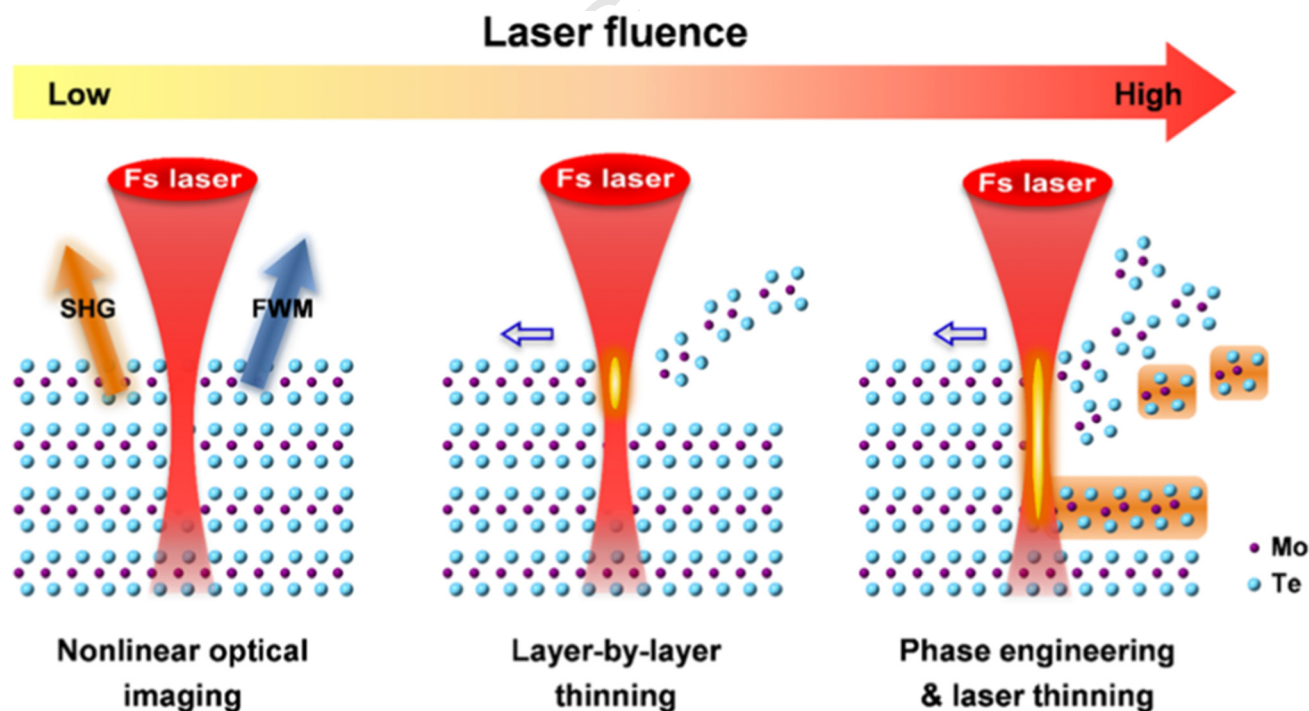
78 precise atomic configurations is crucial
79 for a particular stoichiometry since each
80 polymorph usually has distinctly different
81 electronic and quantum properties. For in-
82 stance, in few-layer MoTe_2 , the atomic con-
83 figuration of a semiconducting hexagonal
84 2H phase can be reorganized to a topo-
85 logical distorted octahedral 1T' phase
86 by CW-laser irradiation that creates Te
87 vacancies [8]. This approach has been
88 used to fabricate an ohmic heterophase
89 homojunction by accurately controlling
90 micron-scale patterning. Alternatively, the
91 extremely high intensities of pulsed ultrafast
92 lasers enable nonlinear optical processes
93 and spectroscopic characterization, for
94 layer-by-layer thinning, or inducing the
95 2H-to-1T' phase transition in few-layer
96 MoTe_2 crystals (Figure 1) [9]. Therefore,
97 while mechanisms responsible for such
98 nonequilibrium processes are still being
99 revealed, it is clear that ultrafast laser
100 processing holds promise to enable

the simultaneous optical characterization,
phase engineering, and nanomanufacturing
of 2D TMDs for fabricating nanoelectronics
devices.

Precisely controlling the growth and doping of 2D materials by laser synthesis

The nonequilibrium processing advantages of laser-based synthesis approaches, including pulsed laser deposition (PLD), are emerging for growth and layer-by-layer implantation of dopants. PLD provides a versatile approach to stoichiometrically laser vaporize and deposit prototype 2D materials from bulk targets to substrates with digital thickness control, substrate-scale uniformity, and with controllable KE [10]. Moreover, the 'building blocks' for growth can be tuned in PLD from atomic and molecular species to nanoparticles for the stoichiometric growth of crystalline 2D materials on substrates, as shown for

GaSe nanosheets grown on insulating
substrates with high spatial uniformity and
thickness control [4]. This approach uses
controlled spatial confinement and thermal-
ization of the ablation products, adjusted
with time-resolved imaging and plasma
diagnostics of the fast-moving laser plasma,
to form and deposit stoichiometric nanopar-
ticle precursors of 2D materials with suffi-
cient flux and KE to efficiently nucleate
triangular ~20-nm domain GaSe nano-
sheets across the substrate that coalesced
to form interconnected networks. Simple
in situ laser reflectivity diagnostics can
provide real-time control over the growth
kinetics during PLD growth of 2D TMDs
and achieve sub-monolayer thickness
precision [11]. Alternatively, the same amor-
phous nanoparticle precursors laser-
deposited onto room temperature sub-
strates can be evaporated to grow large
monolayer crystals onto a nearby substrate
just microns away, as demonstrated for



Q1 Figure 1. Schematic view showing different interactions between MoTe_2 layers and fs laser by varying the laser fluence. (A) Nonlinear optical characterization, (B) precise layer thinning with no phase change, and (C) phase engineering and laser thinning [9]. Abbreviations: FWM, four-wave mixing; SHG, second harmonic generation.

124 monolayer GaSe and MoSe₂ in a 'digital
125 transfer growth' approach [12]. This versa-
126 tile and digital technique allows lithographic
127 pre patterning of the precursors and then
128 transfer of this pattern via subsequent con-
129 fined growth onto a substrate of choice. In
130 addition, lasers can simply provide remote
131 heating for evaporation to grow 2D mate-
132 rials with engineered defect densities. For
133 example, by nonstoichiometrically evapo-
134 rating TMD powders, single-crystalline,
135 monolayer MoSe₂ can be grown with Se
136 vacancy concentrations up to 20%, far be-
137 yond intrinsic values [13]. Interestingly,
138 these Se vacancies can also be repaired

reliably by a follow-on treatment supplying
Se by PLD from a selenium target [13].

Laser-ablation plasmas provide a new
opportunity for implanting dopants into
atomically thin 2D materials and trans-
forming them. The KE of species in typical
PLD plumes is <100 eV/atom and this can
easily be moderated by inert background
gas collisions into the 1–10 eV/atom range
necessary for interacting with monolayer
TMDs, energies far below typical ion implan-
tation techniques. As shown in Figure 2,
by controlling the KE of Se species arriving to
a WS₂ crystal using an Ar background and

in situ plume diagnostics, a very narrow
3–5 eV/atom range allows Se to be selec-
tively implanted into just the plasma-facing
side of a WS₂ monolayer, forming Se-rich
nanoscale domains and causing the ejection
of sulfur dimers as the crystal recrystallizes.
This selective hyperthermal implantation
permits the low-temperature synthesis
of novel Janus monolayers of WSSe
with different chalcogens on either side
[14]. More generally, the tunable KE/Se
atom and digital nature of PLD enables
precise layer-by-layer implantation to control
the Se/S ratio in WS_{2(1-x)}Se_{2x} alloys. With
this technique, multiple lateral hetero-
junctions of MoS₂-MoSe₂ were formed
by selectively converting MoSe₂ to MoS₂ in
lithographically masked regions [15]. This
technique presents a low-temperature,
single-step processing route utilizing hyper-
thermal implantation for the synthesis of
many predicted Janus monolayers and,
more generally, new regimes to implant
dopant atoms for the formation of 2D
Janus materials and alloys using the wide
variety of source atoms available by PLD
with controlled KE in this virtually unexplored
<20 eV range.

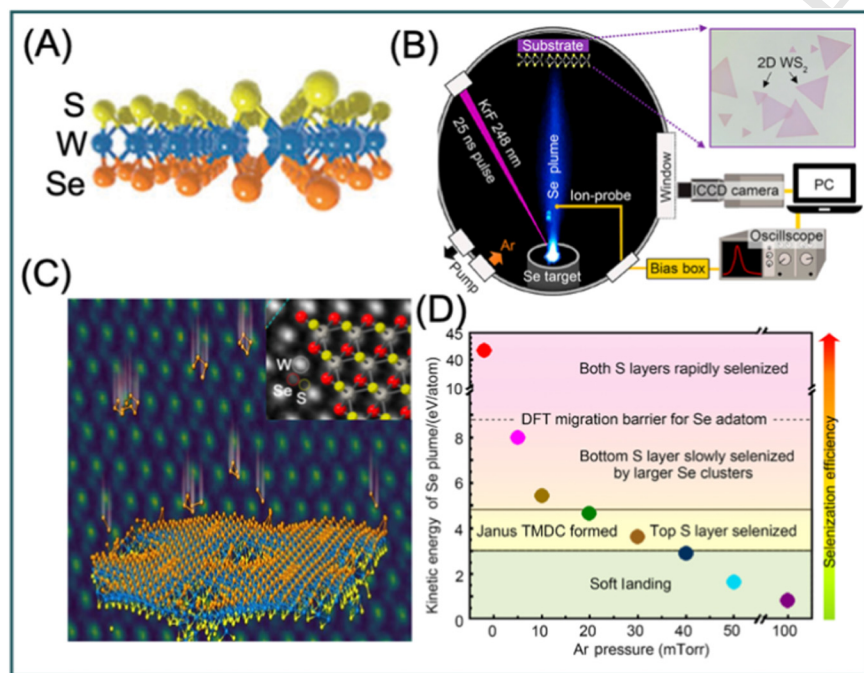


Figure 2. Controlled formation of Janus monolayers using hyperthermal implantation of species in pulsed laser deposition (PLD). (A) Schematic structure of Janus monolayer of WSSe. (B) Gated intensified charge-coupled device (ICCD) imaging and ion probe current measurements are used to record and adjust the kinetic energy (KE) and flux of species arriving at existing, freestanding 2D WS₂ crystals through the use of inert background gas (Ar) collisions that slow the species from 42 eV/Se atom to sub-eV. (C) Molecular dynamics (MD) simulations reveal how Se₂-Se₉ clusters in the plume implant in the suspended monolayer crystals. The background and inset show a tilted scanning transmission electron microscopy image for a WSSe Janus monolayer created at 4.5 eV/atom, confirming all the Se atoms are on 'top' and S atoms on the 'bottom' chalcogen layers. (D) Summary diagram of KE regimes for selenization of WS₂ monolayer by implantation using Se PLD showing KE effects. For lower KE's < 3 eV/atom, a nondamaging 'soft-landing' regime allows encapsulation of the WS₂ crystal in Se. This same approach of soft-landing transition metal dichalcogenide amorphous precursors as as-grown 2D layers, then followed by laser annealing, is promising to epitaxially grow van der Waals heterostructures. For higher KE's > 5 eV/Se atom the WS₂ crystal can be completely converted to WSe₂ [14].

Concluding remarks

Laser-induced nonequilibrium processes offer unique advantages to precisely deposit, thin, etch, dope, direct-write, and tune the phases of atomically thin 2D crystals. In each case, the digital delivery of energy and layered nature of vdW 2D crystals enables the development of selective processes. Indeed, the low-energy, yet hyperthermal kinetic energies inherent to typical PLD plasmas illustrated how precisely atoms can be implanted layer-by-layer in 2D TMDs to make metastable crystals such as Janus monolayers with novel functionalities, including charge separation, piezoelectricity, Rashba effects, and new quantum states. Laser spectroscopy during and after processing not only provides an essential characterization method to remotely understand the structure and properties of laser interactions of 2D

188 materials, but it also provides the key *in situ*
 189 diagnostic to provide real-time feedback
 190 control to optimize laser processing ap-
 191 proaches required for reliable manufactur-
 192 ing. This emerging evolution of combined
 193 laser synthesis, processing, and diagnos-
 194 tics promises not only approaches for the
 195 scalable synthesis of 2D materials with con-
 196 trolled heterogeneity, but transformational
 197 manufacturing approaches for laser-based
 198 direct write and additive manufacturing of
 199 atomically thin materials.

200 Acknowledgments

Q7 This work was supported by the US Department of
 202 Energy, Office of Science, Basic Energy Sciences
 203 (BES), Materials Sciences and Engineering Division
 204 and by Oak Ridge National Laboratory's Center for
 205 Nanophase Materials Sciences (CNMS), which is a
 206 DOE Office of Science User Facility.

207 Declaration of interests

208 No interests are declared.

209 ¹Center for Nanophase Materials Sciences, Oak Ridge National
 210 Laboratory, Oak Ridge, TN 37831, USA

*Correspondence:
xiaok@ornl.gov (K. Xiao) and
geohegandb@ornl.gov (D.B. Geohegan).
<https://doi.org/10.1016/j.trechm.2022.05.007>

© 2022 Elsevier Inc. All rights reserved.

References

1. Cai, H. *et al.* (2021) Heterogeneities at multiple length scales in 2D layered materials: from localized defects and dopants to mesoscopic heterostructures. *Nano Res.* 14, 1625–1649
2. Su, B.W. *et al.* (2021) Laser-assisted two dimensional material electronic and optoelectronic devices. *J. Mater. Chem. C* 9, 2599–2619
3. Kollipara, P.S. *et al.* (2020) Optical patterning of two-dimensional materials. *Research* 2020, 6581250
4. Mahjouri-Samani, M. *et al.* (2014) Pulsed laser deposition of photoresponsive two-dimensional GaSe nanosheet networks. *Adv. Funct. Mater.* 24, 6365–6371
5. Zuo, P. *et al.* (2019) Maskless micro/nanopatterning and bipolar electrical rectification of MoS₂ flakes through femtosecond laser direct writing. *ACS Appl. Mater. Inter.* 11, 39334–39341
6. Castellanos-Gomez, A. *et al.* (2012) Laser-thinning of MoS₂: on demand generation of a single-layer semiconductor. *Nano Lett.* 12, 3187–3192
7. Liu, C.Z. *et al.* (2021) Understanding substrate-guided assembly in van der Waals epitaxy by in situ laser crystallization within a transmission electron microscope. *ACS Nano* 15, 8638–8652
8. Cho, S. *et al.* (2015) Phase patterning for ohmic homojunction contact in MoTe₂. *Science* 349, 625–628
9. Wang, M.M. *et al.* (2020) Nonlinear optical imaging, precise layer thinning, and phase engineering in MoTe₂ with femtosecond laser. *ACS Nano* 14, 11169–11177
10. Wu, Z.H. *et al.* (2021) Large-scale growth of few-layer two-dimensional black phosphorus. *Nat. Mater.* 20, 1203–1209
11. Poretzky, A.A. *et al.* (2020) In situ laser reflectivity to monitor and control the nucleation and growth of atomically thin 2D materials. *2D Mater.* 7, 025048
12. Mahjouri-Samani, M. *et al.* (2014) Digital transfer growth of patterned 2D metal chalcogenides by confined nanoparticle evaporation. *ACS Nano* 8, 11567–11575
13. Mahjouri-Samani, M. *et al.* (2016) Tailoring vacancies far beyond intrinsic levels changes the carrier type and optical response in monolayer MoSe₂-x crystals. *Nano Lett.* 16, 5213–5220
14. Lin, Y.C. *et al.* (2020) Low energy implantation into transition-metal dichalcogenide monolayers to form Janus structures. *ACS Nano* 14, 3896–3906
15. Mahjouri-Samani, M. *et al.* (2015) Patterned arrays of lateral heterojunctions within monolayer two-dimensional semiconductors. *Nat. Commun.* 6, 6365–6371